

Subject Code	Course Name	Teaching Scheme	Credits Assigned					
			Theory	Practical	Tutorial	Theory	TW/ Practical	Tutorial
EXC803	MEMS Technology	04	--	--	04		--	04

Subject Code	Subject Name	Examination Scheme								
		Theory Marks					Term Work	Practical	Oral	Total
		Internal assessment			End Sem. Exam					
		Test 1	Test 2	Ave. Of Test 1 and Test 2						
EXC803	MEMS Technology	20	20	20	80	-	-	-	100	

**Course Pre –requisite:**

- EXC 404: Basic VLSI Design
- EXC 604: IC Technology

**Course Objective:**

- To provide a basic knowledge of MEMS processing steps and processing modules.
- To demonstrate the use of semiconductor based processing modules used in the fabrication of variety of sensors and actuators (e.g. pressure sensors, accelerometers, etc.) at the micro-scale.
- To provide an understanding of basic design and operation of MEMS sensors and transducers.

**Course Outcome:**

**On Completion of this course Student will be able to**

- Understand the underlying fundamental principles of MEMS devices including physical operation, mathematical modeling and fabrication.
- Design and simulate MEMS devices and system using standard simulation tools.
- Develop different concepts of micro system sensors and actuators for real-world applications.

<b>Module No.</b>	<b>Unit No.</b>	<b>Topics</b>	<b>Hrs.</b>
<b>1.</b>		<b>Introduction to MEMS</b>	<b>04</b>
	<b>1.1</b>	Introduction to MEMS & Real world Sensor/Actuator examples (DMD, Air-bag, pressure sensors). MEMS Sensors in Internet of Things (IoT), BioMedical Applications	
<b>2</b>		<b>MEMS Materials and Their Properties</b>	<b>10</b>
	<b>2.1</b>	Materials (eg. Si, SiO <sub>2</sub> , SiN, Cr, Au, Ti, SU8, PMMA, Pt); Important properties: Young modulus, Poisson's ratio, density, piezoresistive coefficients, TCR, Thermal Conductivity, Material Structure. Understanding Selection of materials based on applications.	
<b>3</b>		<b>MEMS Fab Processes – 1</b>	<b>11</b>
	<b>3.1</b>	Understanding MEMS Processes & Process parameters for: Cleaning, Growth & Deposition, Ion Implantation & Diffusion, Annealing, Lithography. Understanding selection of Fab processes based on Applications	
<b>4</b>		<b>MEMS Fab Processes – 2</b>	<b>10</b>
	<b>4.1</b>	Understanding MEMS Processes & Process parameters for: Wet & Dry etching, Bulk & Surface Micromachining, Die, Wire & Wafer Bonding, Dicing, Packaging. Understanding selection of Fab processes based on Applications	
<b>5</b>		<b>MEMS Devices</b>	<b>11</b>
	<b>5.1</b>	Architecture, working and basic quantitative behaviour of Cantilevers, Microheaters, Accelerometers, Pressure Sensors, Micromirrors in DMD, Inkjet printer-head. Understanding steps involved in Fabricating above devices	
<b>6</b>		<b>MEMS Device Characterization</b>	<b>06</b>
	<b>6.1</b>	Piezoresistance, TCR, Stiffness, Adhesion, Vibration, Resonant frequency, & importance of these measurements in studying device behavior, MEMS Reliability	
<b>Total</b>			<b>52</b>

### **Recommended Books:**

1. An Introduction to Microelectromechanical Systems Engineering; 2<sup>nd</sup> Ed - by N. Maluf, K Williams; Publisher: Artech House Inc
2. Practical MEMS - by Ville Kaajakari; Publisher: Small Gear Publishing
3. Microsystem Design - by S. Senturia; Publisher: Springer
4. Analysis and Design Principles of MEMS Devices - Minhang Bao; Publisher: Elsevier Science
5. Fundamentals of Microfabrication - by M. Madou; Publisher: CRC Press; 2 edition
6. Micro Electro Mechanical System Design - by J. Allen; Publisher: CRC Press
7. Micromachined Transducers Sourcebook - by G. Kovacs; Publisher: McGraw-Hill

### **Internal Assessment (IA):**

Two tests must be conducted which should cover at least 80% of syllabus. The average marks of both the test will be considered as final IA marks

### **End Semester Examination:**

1. Question paper will comprise of 6 questions, each of 20 marks.
2. Total 4 questions need to be solved.
3. Question No.1 will be compulsory and based on entire syllabus wherein sub questions of 2 to 5 marks will be asked.
4. Remaining questions will be selected from all the modules